


Brief CV

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|--|--|----------------------------|-------|--|
| Name | Li Yanli | 中文名 | 李艳丽 |  PHOTO |
| Gender | Female | Title (Pro./Dr.) | Dr. | |
| Position (President...) | N/A | Country | China | |
| University/ Department | Institute of Electrical Engineering, Chinese Academy of Sciences/Electron beam lithography technology research group | | | |
| Personal Website | N/A | | | |
| Research Area | materials treatment by electron beam | | | |
| Brief introduction of your research experience: | | | | |
| <p>2014.9-2018.1 Institute of Electrical Engineering, Chinese Academy of Sciences In my doctoral research, my main work is focus on film preparation by electron beam(EB), including MgB₂ superconducting film and ZnO transparent conducting film. In that period I published 7 papers like “Enhanced electrical properties of ZnO transparent conducting films prepared by electron beam annealing ” and “The Fabrication of MgB₂ Film and Nano-Bridge by EB and FIB” and so on.</p> <p>2018.1-now Institute of Electrical Engineering, Chinese Academy of Sciences Now as a researcher, my group’s main work is to continue to explore the application of EB on material.</p> | | | | |

*****All the columns need to be filled in.